

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE BEFORE THE BOARD OF PATENT APPEALS AND INTERFERENCES

Application of: KANO, Takashi et al.

Serial No.: 09/941,982

Examiner: MULPURI, Savitri

Group Art Unit:28:

Filed: August 30, 2001

P.T.O. Confirmation No.: 7536

For: METHOD OF FORMING NITRIDE-BASED SEMICONDUCTOR LAYER, AND METHOD OF MANUFACTURING NITRIDE-BASED SEMICONDUCTOR DEVICE

## **NOTICE OF APPEAL**

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Date: July 8, 2003

Sir:

Applicants hereby appeal to the Board of Patent Appeals and Interferences from the decision dated January 8, 2003 of the Primary Examiner.

The item(s) checked below are appropriate:

1. XX A petition for a third month extension of time to respond to the Final Rejection is file herewith

2. XX A timely response to the Final Rejection has been filed, as provided in 37 C.F.R. 1.113

3. XX Fee -\$320.00 or Small Entity -\$160.00

XX Enclosed

Not required (fee paid in prior appeal)

Charge to Deposit Account No. 01-2340

In the event this Notice of Appeal is not considered to be timely filed, Applicants hereby petition for an appropriate extension of time. The fee for this extension may be charged to our Déposit Account No. 01-2340, along with any other additional fees which may be required with respect to this Notice.

Respectfully submitted,

ARMSTRONG, WESTERMAN & HATTORI, LLP

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